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APPLICATION NO. Nat'l Stage of

JP 2004/011580
107344109

APPLICANT

HIROKATSU MIYATA ET AL.

FILING DATE

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GROUP

1771

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U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	2003/0012931 A1	1-2003	Kuroda et al.	428	188	1/7/2000

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT
WO	2004/015167 A2	2/2004	PCT			

OTHER DOCUMENT(S) (including Author, Title, Date, Pertinent Pages, Etc.)

Besson et al., "A New 3D Organization of Mesopores in Oriented CTAB Silica Films", J. Phys. Chem. B 2000, 104, 12095-12097, XP-002304393

Grosso et al., "Highly oriented 3D-hexagonal silica bromide", J. Mater. Chem., Vol. 10, No. 9, pp. 2085-2089 (2000)

Patent Abstracts of Japan, Vol. 2003, No. 3 (2003)

EXAMINER

/Anish Desai/

DATE CONSIDERED

09/07/2007

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609, Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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